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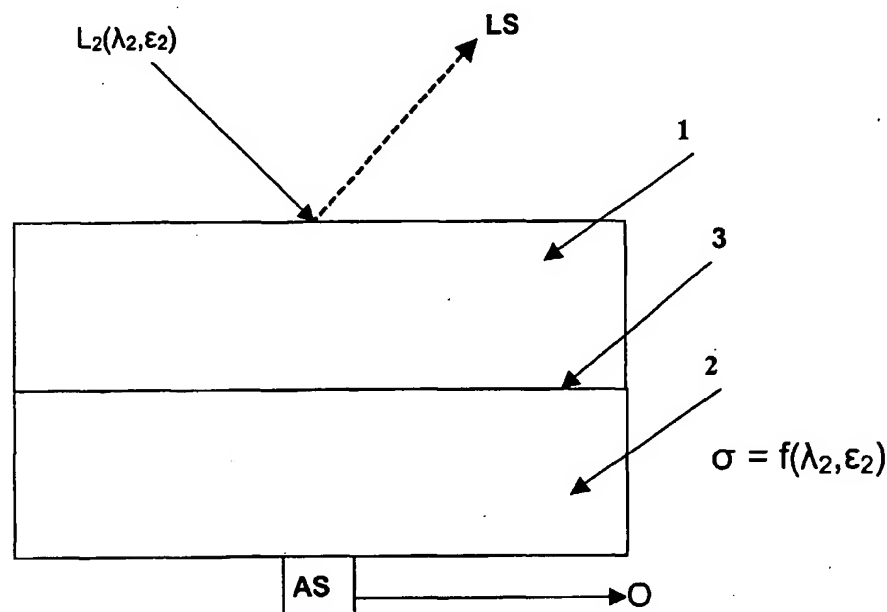
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(54) Title: **METHOD OF ADHESION MEASUREMENT AT THE INTERFACE BETWEEN LAYERS**



(57) Abstract: The strength of adhesion between two layers (1,2) is evaluated by applying a series of laser shocks directly to the surface of one (1) of the layers. Adhesion strength is determined based on the wavelength (λ_2) and energy (ϵ_2) of the laser pulse (L_2) creating the shock which causes rupture of the interface (3) between the two layers (1,2).

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"METHOD OF ADHESION MEASUREMENT AT THE INTERFACE BETWEEN LAYERS"

Field of the Invention

5 The present invention relates to a method of measurement of adhesion strength and, more particularly, to a method of measurement of adhesion strength at the interface between layers in a multi-layer stack, especially in a multi-material stack.

Background Art

10 Microelectronic devices comprising integrated circuits may comprise stacks of layers. There are many situations in which it is desirable to measure the adhesion strength between two layers of material. Typically, this is a requirement during manufacturing processes of said microelectronic devices, when testing products for reliability. Often the two layers will consist of different materials, but it can also arise that there is an interface between two layers made of substantially the same material.

15 During manufacture of such microelectronic devices comprising integrated circuits, it is desirable to measure the adhesion strength between layers in a wafer, notably layers deposited as thin films. Ideally this would be done at various locations across the surface of the wafer. Wafer-testing techniques used to date involving stress-measurement techniques such as the curvature method, or x-ray measurement are described in the publication entitled
20 "Intrinsic stress in chemical vapour deposited diamond films: An analytical model for the plastic deformation of the Si substrate" by J.H. Jeong et al, in the Journal of Applied Physics, 90(3), pp 1227-1236, 1st August 2001. However, these techniques only provide information about residual stress in the wafer in general, they do not provide a measurement of adhesion strength between the different layers in the wafer at specific locations on the wafer.

25 In other fields, various measurement techniques are known which do allow adhesion-strength to be determined. Tests including stress measurement using a microcantilever are known from the publication entitled "Quantitative surface stress measurement using a microcantilever" by M. Godin et al, in Applied Physics Letters, 79(4), pp 551-553, 23rd July 2001. Methods that also include four-point bending techniques are already known from the
30 publication entitled "Adhesion and de-bonding of multi-layer thin film structure" by Dauskardt et al in Eng. Fract. Mech, 61, pp 141-162, 1998. However, the above cited tests are destructive: they require the use of samples of a certain size and said samples are

unsuitable for use after testing. Moreover, these known techniques are not well-suited to multi-material stacks involving thin films of the kind encountered in microelectronic devices.

Other adhesion-strength measurement techniques are known in which the interface between two materials is supplied with power from a laser.

5 For example, US patent 4,972,720 describes a technique for assessing adhesion strength at an interface by heating the interface and evaluating the temperature at which thermal debonding occurs. The interface can be heated by applying laser energy over a relatively extended period (e.g. 5 seconds), and debonding can be detected by various techniques including using an acoustic sensor. The above cited patent US 4,972,720 teaches
10 that interfaces having lower adhesion strength produce noisier debonding events.

There are various disadvantages of the method described in US 4,972,720. Firstly, the materials under test may experience an undesirable change in properties when they are heated. For example, a heated steel sample could undergo a martensitic transformation. Secondly, this known technique will only work when applied to the interface between two
15 materials having different coefficients of thermal expansion.

US patent 5,838,446 describes a technique for determining the strength of adhesion of a transparent coating provided on an opaque basecoat. Laser energy is used to ablate the basecoat at the interface between the basecoat and clearcoat such that a blister forms. Adhesion strength is determined from various parameters including the size of the blister, and
20 a critical energy value at which a crack begins to propagate from the blister. A single IR ($\lambda=1053\text{nm}$) laser pulse of 50 ps width is used to irradiate a single spot on the sample, then the energy value of the laser is changed and a new spot irradiated. At each spot, the radius of the blister that is formed is measured. The radius values from a series of spots are plotted on a graph in order to estimate a radius value for the critical energy. Calculation of the adhesion
25 strength uses this estimated radius value.

There are disadvantages, too, with the method described in US 5,838,446. Notably, ablation of materials is likely to generate dust, which will be undesirable in many manufacturing environments, e.g. in the microelectronics industry. Moreover, this technique requires use of a particular sample geometry which involves handling the sample to an extent
30 which may be undesirable (e.g. if the sample is a semiconductor wafer being used to manufacture microelectronics devices). Further, in order to calculate a single adhesion strength value, measurements must be taken at a number of locations on the sample and the resultant data combined – leading to undue complication and a relatively lengthy calculation time.

US patent 5,438,402 describes a laser spallation technique for determining tensile strength at the interface between a substrate and a coating. In such laser spallation techniques, a mechanical impulse is applied to the substrate and coating. In order for the mechanical impulse to be transmitted to the substrate/coating, it is necessary to provide an energy-absorbing coating on the free surface of the substrate (the surface remote from the coating), and a confinement plate on the energy-absorbing layer. A pulse from a laser is used as the energy source in this arrangement. Adhesion strength is calculated based on the movement of the free surface of the coating.

It is an object of the present invention to provide a new technique for evaluating adhesion strength at an interface between two layers, for example between layers of two different materials in a multi-material stack.

Preferred embodiments of the present invention provide an adhesion-strength evaluation method which is simpler to implement than the methods known heretofore. More particularly, in these preferred embodiments, a value for adhesion strength can be calculated without the need to process data relating to a set of locations on the sample or the need to use a complicated confinement structure.

Preferred embodiments of the invention allow adhesion strength to be measured at discrete locations over a surface.

The present invention provides a method of measuring adhesion strength at the interface between two layers, in which method a laser pulse is caused to impact directly on one of said two layers so as to produce a shock wave at the interface, and a sensor detects rupture of the interface (debonding). The adhesion strength at the interface between the two layers is determined based on the energy and wavelength of the laser pulse required to produce the rupture of the interface.

This technique is extremely simple to put into operation. Adhesion strength can be calculated based on parameters relating to a laser impact at a single point, thus simplifying and speeding up calculation. Moreover, this technique merely involves placing of a wafer, or other multi-material sample, on a pedestal; there is no need to arrange the sample relative to energy absorption layers or confinement plates.

The present invention allows adhesion strength to be measured in a manner which is not globally destructive of the tested sample and without generation of dust. Although there is disruption of the interface at the point(s) where testing is performed, the remainder of the sample is still useable. Thus, the present method is well-suited to testing adhesion strength between layers on a semiconductor wafer which is to be cut up into discrete devices.

Various types of sensor can be used to detect the rupture of the interface between the two layers undergoing test. In preferred embodiments of the invention the sensor is an acoustic sensor or an x-ray reflection device.

The invention and additional features, which may be optionally used to implement the invention to advantage, are apparent from and elucidated with reference to the drawing described hereinafter.

Brief description of the Drawings

Fig.1 is a schematic representation of an arrangement of equipment used to implement a preferred embodiment of the method of the present invention, in which:

10 Fig.1(a) illustrates the case where the interface between materials retains integrity, and

Fig.1(b) illustrates the case where the interface cracks.

Detailed description of the Embodiments

The stress caused by a laser shock applied to a material depends upon the wavelength and the energy of the laser pulse used to produce the shock. More particularly, the higher the wavelength and energy of the laser pulse, the greater the stress that is caused. The behaviour of a surface undergoing a laser shock is described in more detail in "Electron diffusion in metals studied by picosecond ultrasonics" by G. Tas et al, appearing in Physical Review B, 46(21), pp15 046- 15055, 1st June 1994.

20 A laser pulse of appropriate wavelength and energy, impacting directly on a layer of material, can create sufficient stress at the interface between that layer and another to which it is bonded so as to overcome the forces of adhesion between those two layers. (This rupture of the interface between the two layers can be detected, for example using an acoustic sensor or x-ray reflection device. The adhesion strength between the two layers can thus be
25 determined by applying laser pulses of increasing wavelength and/or energy directly to a sample undergoing test, noting the wavelength and energy of the laser pulse which just causes sufficient stresses to provoke rupture of the interface, and calculating a value for adhesion strength based on these critical values of wavelength and energy.

A laser shock can apply a pressure of up to 300 MPa or more which is generally
30 adequate to crack the interface between two layers of material. For example, the adhesion strength of the interface between a layer of Ni and a layer of Si_3N_4 is approximately 100 MPa; the adhesion strength of the interface between a layer of Al and a layer of Si_3N_4 is approximately 100 MPa; and the adhesion strength of the interface between a layer of Nb and

3 cracks. This event creates a sound, the sound waves propagate through the second layer 2 (as illustrated by the black ovals in Fig.1(b)) and can be detected, for example, using the acoustic sensor AS, which outputs a signal O. The adhesion strength ($\sigma_{1,2}$) between the layers 1, 2 is a function of these values of wavelength and energy (λ_2, ϵ_2). More particularly,
 5 the pressure, P, at the surface of the sample can be determined from the following equation:

$$P = 0.622A^{7/16}Z^{-9/16}\lambda^{-1/4}\tau^{-1/8}I^{3/4},$$

where A is the atomic weight of the layer 1, Z is the ionisation degree of the plasma, λ is the wavelength of the laser, τ is the pulse duration and I is the maximum power density of the plasma. (Incidentally, in the case where the laser shock wave traverses more than one layer
 10 before reaching the interface undergoing test, the above equation is applied to each layer traversed).

In a case where a colouring laser is used, it is preferred to set the wavelength of the laser pulse to a first value, λ_1 , and the pulse energy to a first value ϵ_1 , before applying the first pulse to the sample at a given location. If the resulting laser shock is insufficient to cause
 15 debonding at the interface 3, then the pulse energy is increased by an increment $\Delta\epsilon$, and a second pulse is applied to the sample at the same point. The method continues, increasing the laser pulse energy in steps until either debonding occurs at the interface 3 or the maximum possible pulse energy for the laser is reached. If the maximum pulse energy is reached before debonding occurs, then the wavelength of the laser is increased by an
 20 increment, the pulse energy returned to its lowest value, and the process repeated at the new wavelength. Eventually, the wavelength (λ_2) and energy (ϵ_2) values necessary to produce debonding will be reached.

In a case where a single-wavelength laser is used, the testing process preferably consists in setting the pulse energy at an initial value ϵ'_1 for the first pulse applied to the
 25 sample, then ramping up the energy value by an increment $\Delta\epsilon'$ for each subsequent laser pulse, until debonding is detected. Preferably, a laser sensor LS (e.g. a photo-diode) is provided to detect laser light exiting from the free surface of layer 1, namely the light reflected from the free surface of the layer 1 and from the interface between the layers 1/2. The thickness of the first layer can be determined based on the signal detected by the laser
 30 sensor LS. Preferably the metapulse technique is used for this purpose.

Further details of the construction of the laser source, acoustic sensor and laser sensor are not given here because conventional devices can be used to implement these components used in the preferred embodiment of the invention. However, it should be mentioned that the acoustic sensor can be an active or a passive type.

As mentioned above, the adhesion-strength measuring technique of the invention can be used to measure adhesion strength between layers, at different points on a surface. In other words, a series of laser pulses of increasing energy/wavelength would be applied at a point A, until debonding occurs between the layers 1, 2 at point A, then the point of impact
5 on the surface 1 would be changed to a new location, point B. In the above-described embodiment, these points can be spaced apart from each other by a distance of approximately 1 centimetre, or greater.

The drawings and their description hereinbefore illustrate rather than limit the invention. It will be evident that there are numerous alternatives that fall within the scope of
10 the appended claims. For example, although the above-described preferred embodiment illustrated measurement of adhesion strength in a sample comprising two layers, the method according to the invention can also be applied for measurement of adhesion strength between two layers of a sample comprising three or more layers. In such a case, the laser shock will cause debonding at the weakest interface.

15 Furthermore, in the above description of a preferred embodiment of the present invention, it was stated that the energy of successive laser pulses applied at a test point using a colouring laser would be stepped up by an increment of constant size, from an initial lowest value up to a maximum value for the laser being used, before increasing the wavelength from a low value to the next highest value. However, other patterns of variation of the pulse
20 energy/wavelength are possible. For example, depending upon the nature of the sample under test, it may be preferred to start with a pulse energy which is already close to the maximum and/or with a wavelength which is not the lowest wavelength of the laser. Moreover, the size of the increment in energy and/or wavelength may be set differently depending upon the nature of the material(s) at the interface undergoing test.

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The drawings and their description hereinbefore illustrate rather than limit the invention. It will be evident that there are numerous alternatives that fall within the scope of the appended claims. For example, although the above-described preferred embodiment illustrated measurement of adhesion strength in a sample comprising two layers, the method according to the invention can also be applied for measurement of adhesion strength between two layers of a sample comprising three or more layers. In such a case, the laser shock will cause debonding at the weakest interface.

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